



Co-adsorption of O₂ and H₂O on Al(111) surface: a vdW-DFT study

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Using first-principles calculations based on van der Waals density functional theory, we systematically studied the co-adsorption behavior of H₂O and O₂ on Al(111) surfaces. The study consists of two parts: (i) the adsorption of H₂O molecules on O pre-adsorbed Al(111) surfaces, and (ii) co-adsorption of H₂O and O₂ molecules on a clean Al(111) surface. H₂O adsorbs on O pre-adsorbed Al(111) surfaces in the form of a molecule, while both the adsorption energies and partial density states results prove that the adsorption of H₂O is strengthened with the increasing pre-adsorbed O coverage. An Al atom bonded with H₂O is pulled out of the surface in all adsorbed structures because of the repulsion between pre-adsorbed O atoms and the O atoms of H₂O. For the co-adsorption of H₂O and O₂ on a clean Al(111) surface, H₂O molecules can dissociate into OH and H when both of the two O atoms of O₂ can interact with H atoms of H₂O, or else they will adsorb on the surface keeping the behavior of single adsorption. For the dissociation adsorption of H₂O, the redistribution of charge occurs and the value of charge transfer from the surface and O₂ to H₂O is much larger than that of molecular adsorption, which is larger than 0.1.

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1. Introduction

The oxidation of Al (by O₂ or H₂O) is one of the most thoroughly studied reactions^{1–15} because of the importance of this chemical interaction in electrochemistry, heterogeneous catalysis, and corrosion. Studies concerning the chemisorption and dissociation of O₂ and H₂O molecules are of major significance because they are the fundamental steps for the oxidation of Al which is an important process anywhere Al is used. The mechanisms of O₂ molecule chemisorption and dissociation on Al surfaces have been studied using a large variety of experimental and theoretical techniques.^{1–10} Experiments and theoretical calculations support chemisorption only on the fcc site of the first layer of Al(111),^{7,9} and O₂ does not penetrate into subsurface sites.¹⁰ Brune *et al.*⁷ studied the adsorption behavior of O₂ on the Al(111) surface by using a scanning tunneling microscope, they found that O₂ is far from steady under room temperature and dissociation O atoms are adsorbed with monatomic shape. The interaction of H₂O with metal has been the subject of numerous surface science investigations.^{11–14} Some of these studies can develop a general description of the structure, bonding and reactivity of H₂O with clean and O pre-adsorbed surfaces.^{4,5} Netzer and Madey's study indicates that H₂O adsorbed on clean Al(111) trend to O atom close to surface

and H atoms away from surface.¹⁵ At 80 K, they also found that H₂O is adsorbed predominantly in molecular form, and bonding occurs through the O atom, with the molecular axis tilted away from the surface normal.

Co-adsorption behaviors of gas molecules on metal surfaces have been subject to extensive studies.^{16–21} However, little work has been done on the co-adsorption behavior of O₂ and H₂O on Al surface, which is of significance for the passive film forming and corrosion resistance.^{22,23} Only a few studies concerning the adsorption of H₂O on O pre-adsorbed Al surface have been investigated.^{12–14} J. E. Crowell *et al.*¹³ investigated the adsorption of H₂O on both clean and O pre-adsorbed Al(111) surface by vibrational spectroscopy using electron energy loss spectroscopy. On the clean surface, adsorption is predominantly molecular, while in the presence of oxygen, adsorption is predominantly dissociative. Besides, the production of adsorbed hydroxyl species from H₂O reaches a maximum at 250 K on the clean surface and at 350 K on the O pre-adsorbed surface. The hydroxyl species decompose above these temperatures to evolve hydrogen and further oxidize the Al(111) surface. Guo *et al.*¹⁴ symmetrically studied the adsorption behavior of a single molecular H₂O on a clean and an O pre-adsorbed Al(111) surface, and also its corresponding dissociation reactions using first-principle method based on DFT. The results also showed that the adsorption O can promote the dehydrogenation of H₂O.

We have already studied the single adsorption of O₂ and H₂O on clean Al(111) surface and the effect of pre-adsorbed O atoms on the adsorption of H₂O in our previous work.²⁴ In this study, we have utilized first-principles method based on van der Waals

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density functional density (vdW-DFT)²⁵ to examine the co-adsorption behavior of O₂ and H₂O. The adsorption of H₂O on O pre-adsorbed Al(111) surfaces with different O coverage is further calculated based on previous study to investigate the effect of the coverage of pre-adsorbed O atoms on the dissociation of H₂O. The co-adsorption of O₂ and H₂O on Al(111) surface is investigated initiated from eight different configurations. We study the structures and electronic properties of all calculated configurations to investigate the oxidation of Al by O₂ and H₂O.

2. Computational details

All calculations presented in this work are carried out utilizing MedeA-VASP 5.4 software,^{26,27} which is a fast and highly reliable electronic structure method based on DFT.²⁸ The calculation is conducted in a plane-wave basis, using the projector-augmented wave method.²⁹ According our previous results,²⁴ all calculations only involving O atoms were performed by standard DFT method with a spin polarization, which is a calculation based on the GGA-PBE exchange-correlation functional for describing the interactions. The vdW-DFT taking into account in an approximate manner the dispersive forces and van der Waals interactions are used for the adsorption of H₂O molecule co-adsorption of H₂O and O₂. The optimized van der Waals functional based on the Becke 86 (optB86-vdW^{30,31}) is chose as the exchange functional, which trend to exhibit smallest errors for most systems investigated. The non-local vdW correlation was not defined for a spin polarized system. This approach does not rely on empirical force field and is true first principles technique, which is a strict algorithm. OptB86-vdW was mostly used to treat van der Waals type of systems, achieving quite good success.³²⁻³⁴

The adsorption calculations are conducted on 6-layer slabs of Al(111) with a 12 Å vacuum gap. A (3 × 3) mesh is used for the adsorption calculation of a single H₂O molecule on O pre-adsorbed surface and a (4 × 4) supercell is used to co-adsorption. The adsorbates and the three uppermost surface layers are allowed to move freely, and the bottom three layers are fixed. The electronic iterations convergence is 10⁻⁵ eV using the normal (blocked Davidson) algorithm. Periodic boundary conditions are set, leading to an infinite periodic system. The slab models are calculated with a (4 × 4 × 1) and (3 × 3 × 1) Monkhorst-Pack grid³⁵ for two size supercells, respectively. All calculations are performed using a 520 eV cut off energy. The post-processing of results based on structure and charge density is constructed by VESTA.³⁶

The so-called Bader scheme for dividing slab model into atomic regions has been used,³⁷ which proved to be robust and efficient. Included in MedeA-VASP as a property module, this approach is based on a classic algorithm proposed by Bader, as implemented by Henkelman *et al.*³⁸ The surface work function is the energy to extract one electron from surface to vacuum, which is calculated to characterize the surface electronic state. The property of partial density of states (PDOS) is calculated to investigate the interaction among H₂O molecule with surfaces. The adsorption energy (E_{ad}) values are calculated from the following expression:

$$E_{ad} = E_{ads} + E_{sub} - E_{ads/sub} \quad (1)$$

E_{ads} , E_{sub} and $E_{ads/sub}$ are the total energy of the isolated adsorbate, the relaxed clean slab and the slab covered with adsorbates. According to this definition, a larger adsorption energy means stronger interaction between adsorbates and the substrate.

3. Results and discussions

3.1 Structures of O(fcc) pre-adsorbed Al(111) surface

O₂ can adsorb on multiple original positions on Al(111) surface. Dissociated O atoms can stable adsorbed at fcc sites, which is investigated by both theoretical and experimental studies.³⁹⁻⁴¹ The optimized structures and electronic properties of the adsorption of O atoms on fcc sites are investigated in this section. O atoms are arranged at fcc sites in the order of Fig. 1, corresponding to the coverage from 1/9 ML to 1 ML. Geometrical parameters, surface work function, adsorption energies and charge transfer from surface to each O atom are listed in Table 1. Considering the computational error, the charges transfer from Al atoms to each O atom is around 1.7e and independent on the O coverage, which is also demonstrated by the similar Al-O distance at around 1.8 Å. The average distances of Al-O in all adsorbed structures are all smaller than the radius sum of Al³⁺ and O²⁻ (ref. 14) indicating a stronger interaction between Al and O by the form of chemical bond. The adsorption energies referenced O atoms are basically consistent with previous results.⁴¹ The average adsorption energy of each O atom increases with the increasing O coverage from 1/9 ML to 1 ML according to the results in Table 1. The electronic property of surface can be characterized by the parameter of work function which increases with the increasing O coverage (Table 1) indicating that the ability in offering electrons of surface is weakened due to the adsorption of O atoms, which will reflect its adsorption behavior. The adsorbed O atoms will capture electrons of Al atoms and this ability will strengthen with the increasing O coverage, which result in the surface work function increases.

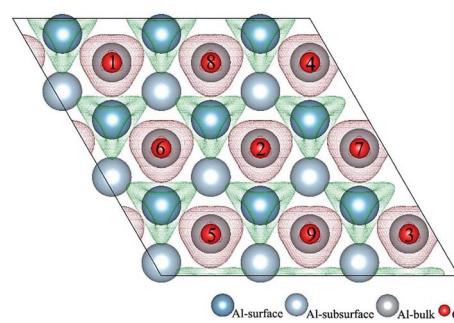


Fig. 1 The difference charge density of O(fcc) atoms pre-adsorbed Al(111) surface. The 1–9 is the occupied order of O atoms. Red parts indicate a behaviour of accepting electrons and green parts indicate a behaviour of losing electrons.



Table 1 Geometrical parameters, surface work function, average charger transfer from surface Al atoms to each O atom and average adsorption energies referenced single O atom of O(fcc) pre-adsorbed Al(111) surface

O coverage/ ML	Distance/Å Al–O (average)	Work function/eV	Charge transfer (Al → O)	Adsorption energy/eV
0	—	4.088	—	—
1/9	1.87	4.085	1.72	7.53
2/9	1.86	4.093	1.73	7.55
3/9	1.85	4.126	1.73	7.55
4/9	1.84	4.156	1.71	7.71
5/9	1.84	4.200	1.70	7.83
6/9	1.83	4.265	1.70	7.90
7/9	1.82	4.334	1.70	7.97
8/9	1.82	4.404	1.68	8.01
1	1.80	4.476	1.68	8.07

3.2 Adsorbed structures of H₂O on clean and O(fcc) pre-adsorbed Al(111) surfaces

We have studied the adsorption of a single H₂O molecule on the clean and O(fcc) pre-adsorbed Al(111) surfaces. The adsorbed structures are shown in Fig. 2 and 3. The geometrical parameters, adsorption energies and charge transfer are listed in Table 2. As previous studies,^{14,15} the results shows that H₂O adsorbed on clean Al(111) surface tends to O atom close to surface and H atoms away from surface, and bonding occurs through the O atom, with the molecular plane titled away from the surface normal. As similar as the clean Al(111), H₂O adsorbs preferentially at the Al top site of the O(fcc) pre-adsorbed surfaces. Al atom bonded with H₂O is pulled out of the surface with the increasing O coverage accompanied by the surface reconstruction. The distance of Al–O decreases from 2.17 Å to 1.93 Å with the increasing O coverage (Fig. 3). The

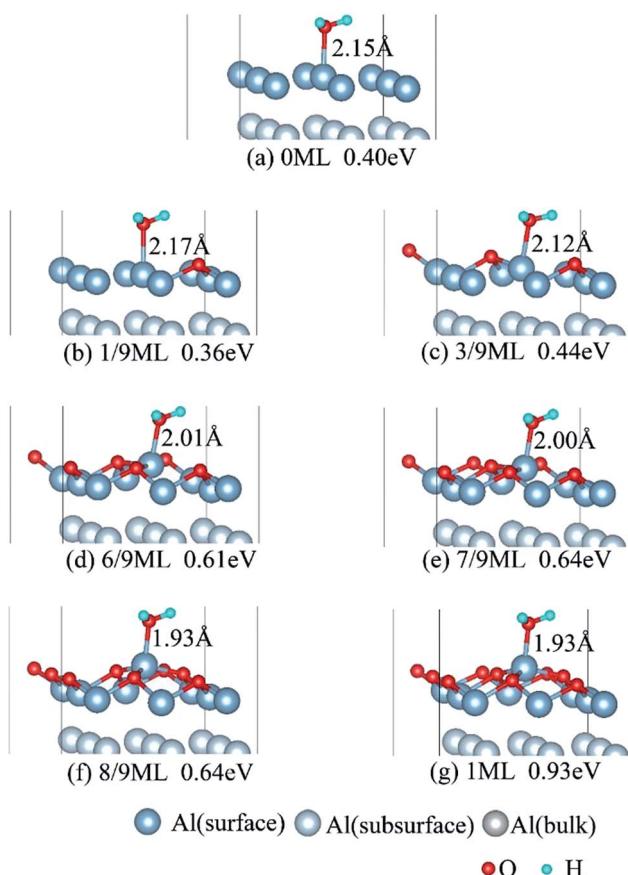


Fig. 3 The side view of adsorbed structures of H₂O on O(fcc) pre-adsorbed Al(111) surfaces.

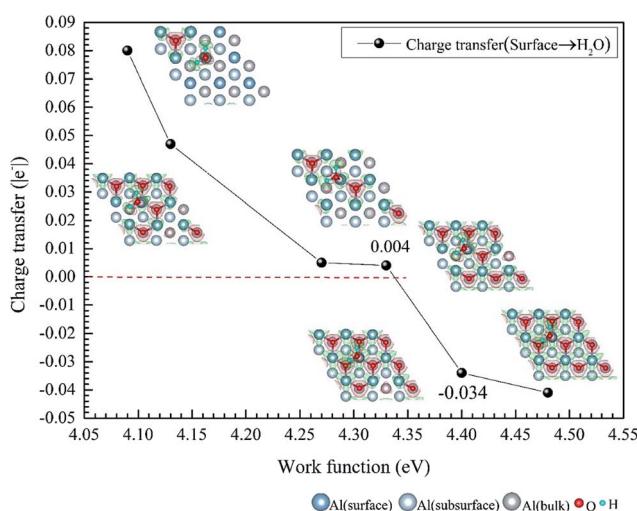


Fig. 2 The relationship between surface work function of O(fcc) pre-adsorbed Al(111) surfaces and charge transfer from surface to H₂O. The top view configurations are the difference charge density of adsorbed structures.

distances are basically equal to the sum of O²⁻ radius and Al³⁺ radius when the O coverage is equal or greater than 7/9 ML indicating a stronger chemical interaction. The deformation of H₂O is also investigated. The average distance of O–H is 0.98 Å in all structures which is a little larger than that in gas and the \angle HOH tends to slightly increase with the increasing O coverage. Based on the results in Table 2, the adsorption energies of H₂O on O(fcc) pre-adsorbed Al(111) surfaces did not monotonically increase with the increasing the O coverage. We infer that the effect of pre-adsorbed O atoms on H₂O adsorption is dependent on the distance between the pre-adsorbed O and the adsorbed Al site by H₂O. At the coverage of 1/9–3/9 ML, H₂O adsorption energy is similar to that on the clean surface, due to the fact that pre-adsorbed O does not form bonds with the adsorbed Al site by H₂O, while the adsorption energy of H₂O is increased obviously when the O coverage increase to 1 ML, due to the strong interaction between pre-adsorbed O atoms and the adsorbed Al site by H₂O. It is noteworthy that the direction of charge transfer changes at the O coverage interval between 7/9 ML and 8/9 ML. The ability of accepting electron of surface is stronger than that of H₂O molecule when the O coverage is greater than the critical value. The adsorption energies are small at the low O coverage while it increases greatly when the O coverage is larger than 7/9 ML, which indicates that H₂O prefer to interact with O pre-adsorbed Al(111) surface by losing



Table 2 Geometrical parameters, adsorption energies and charge transfer from surface to H_2O for the adsorption of H_2O on O(fcc)-pre-adsorbed Al(111) surfaces

O coverage/ML	Distance/ \AA			Adsorption energy/eV	Charge transfer (surf. \rightarrow H_2O)
	Al-O(H_2O)	H-O	Angle $\angle \text{HOH}^{\circ}$		
0	2.15	0.98	106.5	0.40	0.081
1/9	2.17	0.98	107.3	0.36	0.080
3/9	2.12	0.98	106.0	0.44	0.047
6/9	2.01	0.98	107.8	0.61	0.005
7/9	2.00	0.98	108.1	0.64	0.004
8/9	1.93	0.98	108.4	0.94	-0.034
9/9	1.93	0.98	108.4	0.93	-0.414

electrons. Fig. 2 shows the relationship between surface work function of O pre-adsorbed Al(111) surfaces and charge transfer from surface to H_2O . With the increasing O coverage, the charge transfer decreases with the increasing surface work function of O(fcc) pre-adsorbed Al(111) surfaces.

To better understand the interaction of the H_2O molecule with the surface Al atoms, we calculated the PDOS of p orbital of O atom in H_2O molecule and Al atom interacted with H_2O molecule directly. The results are shown in Fig. 4. As can be seen, Fig. 4a–c shows the resonance of O(p) peak of H_2O molecule and Al(p) peak of surface at the O coverage of 3/9, 6/9 and 1 ML, which indicates that there is an obvious interaction

between them. Fig. 4d is the PDOS of O(p) of H_2O adsorbed on the surface with O coverage of 3/9, 6/9 and 1 ML and H_2O molecule in gas. The downshift of O(p) state with respect to the gas is characterized by the displacement of the peak. The result illustrates that the ranking of the adsorption strength of H_2O on surface is O(fcc) pre-adsorbed surface (1 ML) > O(fcc) pre-adsorbed surface (6/9 ML) > O(fcc) pre-adsorbed surface (3/9 ML) > clean surface. We infer that surface with high O coverage favor the H_2O -Al(111) surface interaction which agrees with the previous results of geometrical parameters and adsorption energies.

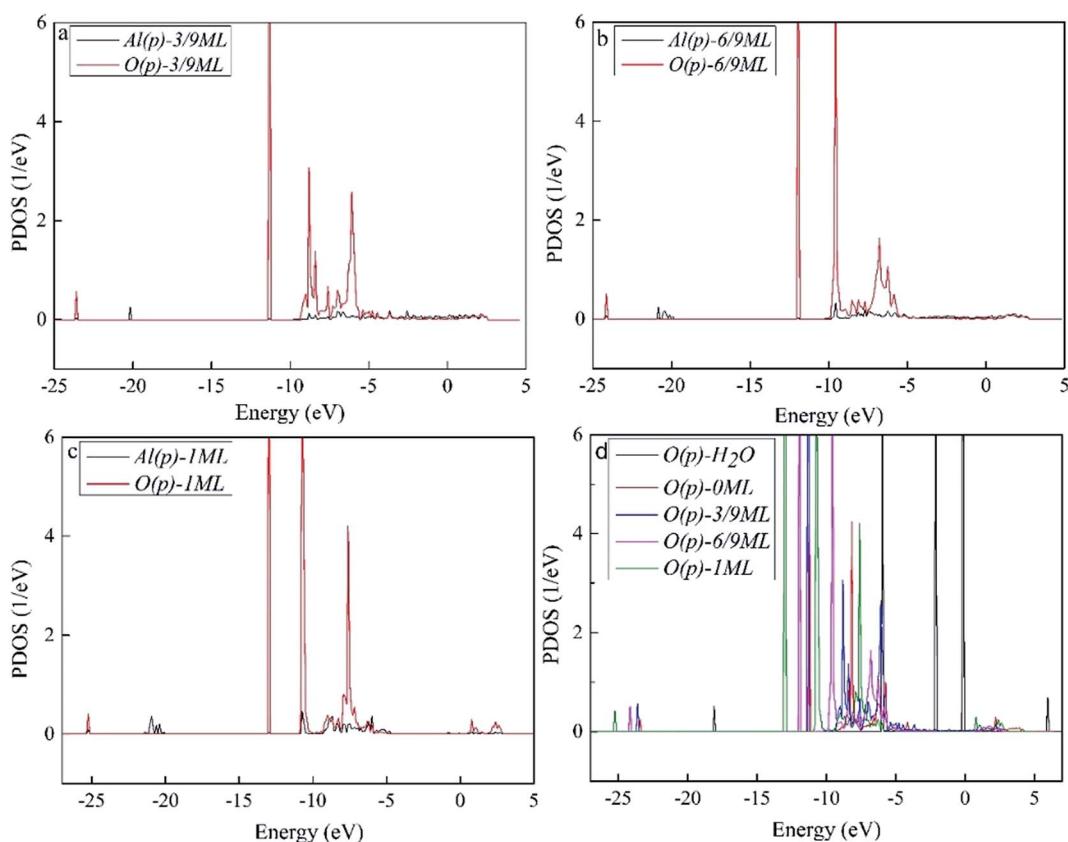


Fig. 4 The PDOS results of (a) Al(p) and O(p) of H_2O adsorbed Al(111) surface at the preadsorbed O coverage of 3/9 ML, (b) Al(p) and O(p) of H_2O adsorbed Al(111) surface at the preadsorbed O coverage of 6/9 ML, (c) Al(p) and O(p) of H_2O adsorbed Al(111) surface at the preadsorbed O coverage of 1 ML, and (d) O(p) of H_2O at the preadsorbed O coverage of 0, 3/9, 6/9 and 1 ML and H_2O in gas.



3.3 Co-adsorption of H_2O and O_2 molecule on clean Al(111) surface

The result of section 3.2 illustrates that the pre-adsorbed O atoms can promote the deformation of H_2O and strengthened its adsorption on Al(111) surface with the increasing O coverage. The transition states search results of our previous study²⁴ and the work of Guo *et al.*¹⁴ also proved that the existence of pre-adsorbed O atom can greatly reduce the dissociation energy of H_2O . In this section, the effect of O_2 molecule on the dissociation and adsorption of H_2O on Al(111) surface is investigated. Eight initial structures are calculated to investigate the co-adsorption behavior, which are marked from Co-1 to Co-8. The adsorbed structures can be classified into two groups which are the dissociated and molecular adsorption of H_2O on Al(111) surface, which are listed in Tables 3 and 4, respectively. O_2 molecule dissociates into O atoms and adsorbs on surface fcc or hep sites in all structures, while H_2O dissociates into OH and H only from Co-1, Co-2 and Co-3 structure, and adsorbs on surface top site by the form of molecule in the adsorbed structures of Co-4, 5, 6, 7, and 8. For the dissociated structures of H_2O , OH adsorbs on top site and H bonds with O atom dissociated from O_2 to produce OH which adsorbs on bridge site. For the adsorbed structure of Co-5, one of O atoms

dissociated from O_2 is permeated into subsurface, which is resulted by the co-adsorption of H_2O . The geometrical parameters, adsorption energies and charge transfer from surface and O₂ to H_2O of the co-adsorbed structures of H_2O and O_2 on clean Al(111) surface are listed in Table 5. Considering the distance between Al and O of OH and H_2O , the binding force of Al-OH is stronger than that of Al- H_2O . The bond of O-H is elongated in OH corresponding to H_2O molecule and there is an obvious deformation of H_2O related the angle of $\angle\text{HOH}$.

The co-adsorbed energy was calculated referenced by O_2 and H_2O molecule according following equation:

$$E_{\text{co-ad}} = E_{\text{O}_2} + E_{\text{H}_2\text{O}} + E_{\text{Al(111)}} - E_{\text{co-ads/sub}} \quad (2)$$

E_{O_2} , $E_{\text{H}_2\text{O}}$ and $E_{\text{Al(111)}}$ are the total energy of the isolated O_2 molecule, H_2O molecule and the relaxed clean slab, and $E_{\text{co-ads/sub}}$ is the total energy of the surface covered with the adsorbed O_2 and H_2O . The co-adsorption energy of H_2O and O_2 on clean Al(111) surface contains three parts: (i) the dissociated adsorption energy of O_2 , (ii) the molecular or dissociated adsorption energy of H_2O and (iii) the interaction energy of O_2 and H_2O during the reaction process. According to the co-adsorbed structure of the dissociation O_2 and H_2O (Co-1, Co-2 and Co-3), the adsorption energies of OH on top and

Table 3 The co-adsorbed structures of the dissociated H_2O for the co-adsorption of H_2O and O_2 on clean Al(111) surface

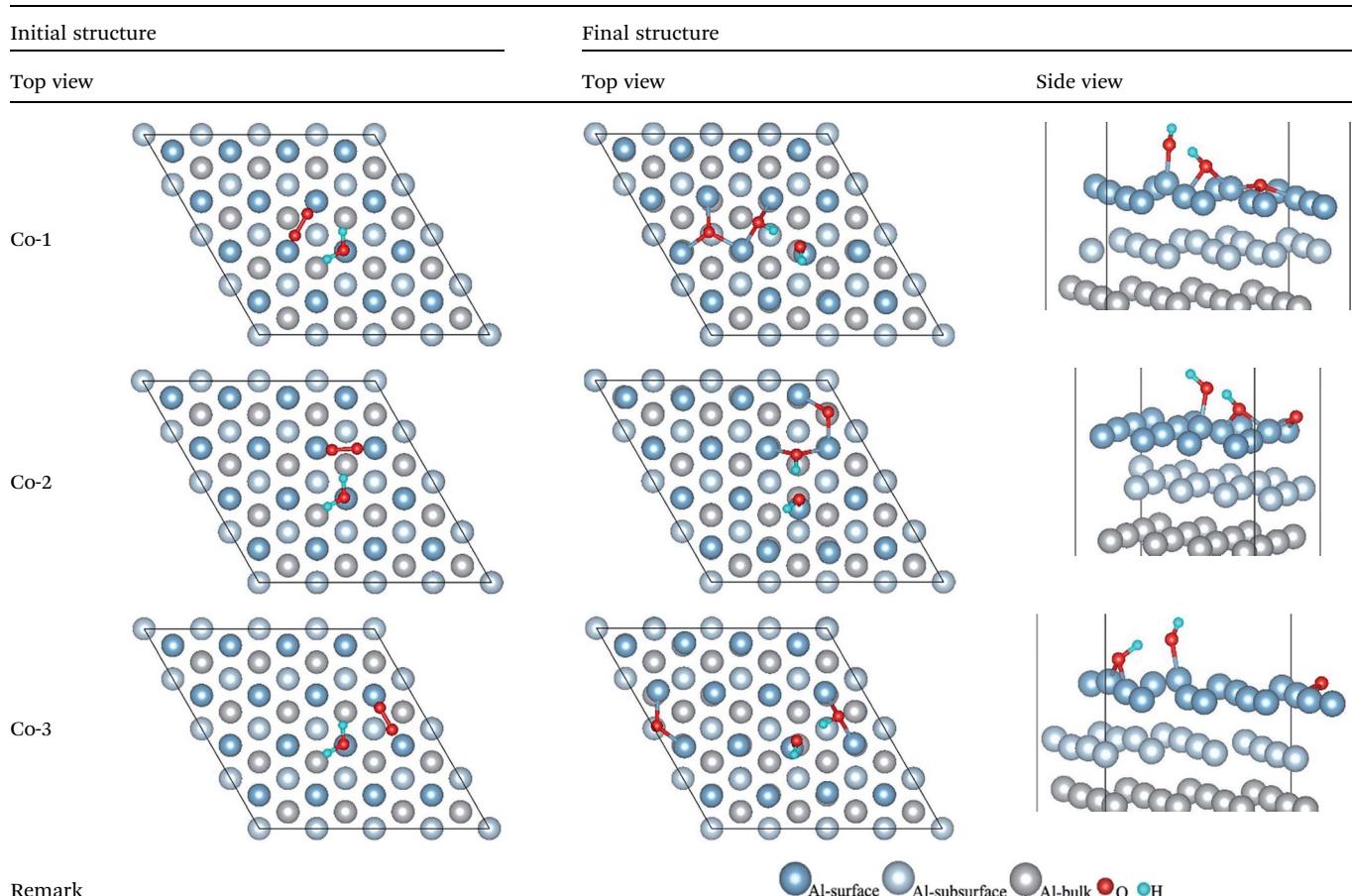
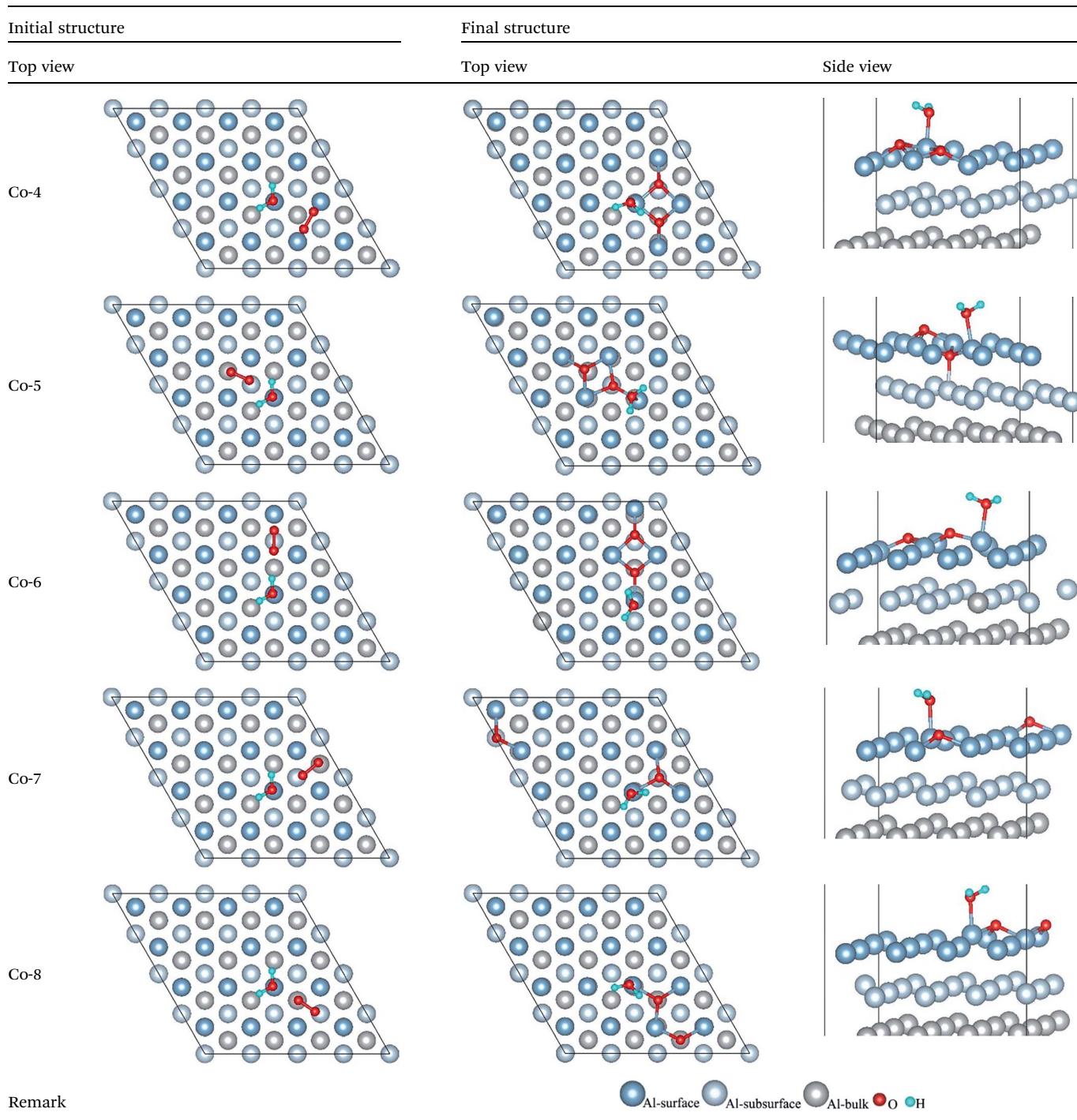


Table 4 The co-adsorbed structures of the molecular H_2O for the co-adsorption of H_2O and O_2 on clean Al(111) surface

bridge site are calculated, which are 1.21 eV and 1.19 eV. The dissociated adsorption energy of O_2 is 8.43 eV when the two O atoms adsorbed on the nearest neighbor fcc sites and $E_{\text{ads}} = 0.40$ eV for one H_2O adsorption. Compared with the co-adsorption energies of H_2O and O_2 (Table 5) and the adsorption energy of single O_2 on Al(111) surface, the co-adsorption energies are basically contributed by the O_2 adsorption. That is why the co-adsorption energy is similar for the dissociated and molecular adsorption of H_2O . Similarly, most of charges

of surface transfer to O_2 molecule to make it dissociated. Fig. 5 shows the difference charge density of co-adsorbed structures (Co-1 and Co-5). Charges transfer from Al atoms and H atoms to O atoms. The charge transfer from surface and O_2 to H_2O of Co-1 is obviously larger than that of Co-5 indicating that offering enough charge to H_2O is one of the necessary condition for the dissociation. Otherwise, H_2O will remain the molecular form on surface.



Table 5 Geometrical parameters, adsorption energies and charge transfer from surface to adsorbates of the co-adsorbed structures of H_2O and O_2 on clean Al(111) surface

Adsorbed structure	Distance/Å					Charge transfer	
	Al-O($\text{H}_2\text{O}/\text{OH}$)					Angle $\angle \text{HOH}^{\circ}$	E_{ads} /eV
	Top	Bridge	Al-O(O_2)	H-O($\text{H}_2\text{O}/\text{OH}$)	Surface + $\text{O}_2 \rightarrow \text{H}_2\text{O}$		
Co-1	1.81	1.88	1.84	1.00	—	—	9.01
Co-2	1.81	1.86	1.84	1.01	—	—	9.33
Co-3	1.81	1.88	1.84	1.00	—	—	9.00
Co-4	2.01	—	1.85	0.98	108.1	—	9.32
Co-5	2.07	—	1.88	0.98	108.5	—	9.12
Co-6	2.08	—	1.85	0.98	108.5	—	8.95
Co-7	2.07	—	1.86	0.98	109.9	—	9.25
Co-8	2.07	—	1.86	0.98	108.6	—	9.78
							0.154
							0.133
							0.163
							0.026
							0.085
							0.037
							0.045
							0.040

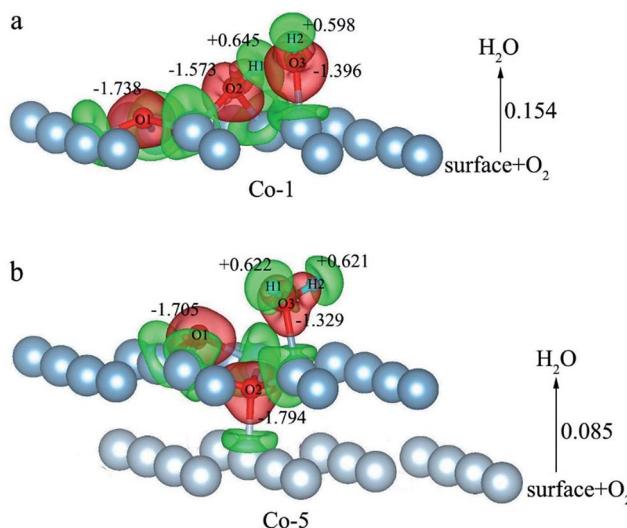


Fig. 5 The difference charge density of structures of Co-1 and Co-5 for the co-adsorption of H_2O and O_2 on Al(111) surface.

4. Conclusions

First-principles calculations based on vdW-DFT have been performed to investigate the co-adsorption behavior of H_2O and O_2 molecule on Al(111) surfaces. Two types models, adsorption structures of H_2O on O(fcc) pre-adsorbed Al(111) surface and co-adsorbed structures of H_2O and O_2 on clean Al(111) surface, are selected and their interaction carefully analyzed. The key results of our study are:

1. O atoms can stable adsorb on fcc sites of Al(111) surface and their adsorption energy referenced single O atom increases with the increasing O coverage. The adsorbed O atoms change the electron density of surface which makes the surface work function increases from 0 to 1 ML.

2. As similar as the clean Al(111), the H_2O adsorbs preferentially at the top site of surface. The adsorption is strengthened by increasing the adsorbed O coverage on fcc sites. Although the adsorbed O atoms on fcc sites promote the deformation of H_2O and strengthened with the increasing O coverage, but they cannot make it dissociated into OH and H.

3. For the co-adsorption of H_2O and O_2 on clean Al(111) surface, H_2O can dissociate into OH and H in Co-1, Co-2 and Co-3 structure and adsorb on surface by molecular form in remaining structures, which indicates that the existence of O_2 can make H_2O dissociated. A necessary condition dissociation is offering enough charge to H_2O molecule, which is larger than 0.1.

To sum up, O_2 can dissociate into O atoms and adsorb on surface, while the dissociation adsorption of H_2O relates to many factors. The effect of adsorbed O and O_2 molecule on the dissociation of H_2O is discussed in this study. The reaction mechanism of H_2O dissociation concerning other factors will further study in our subsequent work.

Acknowledgements

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